

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent of:)	
	:	
Takako YAMAGUCHI et al.)	Examiner: J. S. Ruggles
	:	
Application No.: 10/779,786)	Group Art Unit: 1756
	:	
Filed: February 18, 2004)	Confirmation No.: 9842
	:	
For: NEAR-FIELD EXPOSURE APPARATUS AND)	October 3, 2007
NEAR-FIELD EXPOSURE PHOTOMASK	:	
)	
U.S. Patent No. 7,190,438 B2	:	
)	
Issued: March 13, 2007	:	

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450
Attention: Certificate of Correction Branch

REQUEST FOR
CERTIFICATE OF CORRECTION
UNDER RULES 322 AND 323

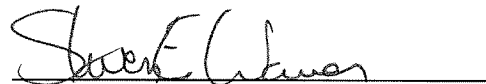
Sir:

Patentees request that a Certificate of Correction be issued by the Patent and Trademark Office due to errors which appear in the printed patent as a result of U.S. Patent and Trademark Office mistakes and mistakes of a minor nature which are not the fault of the U.S. Patent and Trademark Office.

The statutory fee of \$100.00 is being paid electronically. Any additional fee required by this paper may be charged to Deposit Account No. 06-1205.

Patentees' undersigned attorney may be reached in our Washington, D.C. Office by telephone at (202) 530-1010. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,

A handwritten signature in dark ink, appearing to read "Steven E. Warner", is written over a horizontal line.

Attorney for Patentees
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UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 7,190,438 B2

DATED : March 13, 2007

INVENTOR(S): Takako YAMAGUCHI et al.

Page 1 of 1

It is certified that errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

ON THE COVER PAGE:

In item “(56) **References Cited**,” under “FOREIGN PATENT DOCUMENTS,” the second-listed document “JP 61065250 A * 4/1986” should read
-- JP 61-065250 A * 4/1986 --.

COLUMN 11:

Line 21, “less” should read -- lesser --.

COLUMN 12:

Line 36, after “and” the right margin should be closed up and a new paragraph begun on the next line with “a photomask including:”

Line 41, “portion” should read -- portion, --.

Line 42, “the” should read -- wherein exposure is conducted with the --.

Line 54, “between the” should read -- between the substrate and the --.

MAILING ADDRESS OF SENDER:

PATENT NO. 7,190,438 B2

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